Silicon has long been established as the material of choice for the microelectronics industry. This is not yet true in photonics, where the limited degrees of freedom in material design combined with the indirect bandgap are a major constraint. Recent developments, especially those enabled by nanoscale engineering of the electronic and photonic properties, are starting to change the picture, and some silicon nanostructures now approach or even exceed the performance of equivalent direct-bandgap materials. Focusing on two application areas, namely communications and photovoltaics, we review recent progress in silicon nanocrystals, nanowires and photonic crystals as key examples of functional nanostructures. We assess the state of the art in each field and highlight the challenges that need to be overcome to make silicon a truly high-performing photonic material.

Crystalline silicon (c-Si) is the most important semiconductor material for the electronics and photovoltaics industries today, and it has become the cornerstone of our knowledge-based society. This prominent position follows from a unique combination of advantageous properties: the availability of large single crystals, high purity, effective conductivity engineering, a matching insulator and, very importantly, natural abundance. These properties have enabled the electronics industry to follow Moore’s law for over four decades, which is truly remarkable and which has driven the development of silicon technology to its present maturity. Together with its 1.1-eV bandgap — optimal for capturing the solar spectrum using a single-junction device — this maturity makes silicon almost ideally suited for photovoltaics applications. As a result, around 90% of solar panels in use today are based on silicon.

The optical properties of c-Si are relatively poor, owing to its indirect bandgap which precludes the efficient emission and absorption of light. This is a considerable weakness, especially given that some properties of c-Si are already very good, as illustrated, for example, by the successful realization of Raman lasing\(^1\) and the demonstration of ultrafast electro-optic modulation\(^2\).\(^3\). High performance in all aspects of optical functionality is highly desired, as it would enable true optoelectronic integration and pave the way to faster, highly integrated and low-cost devices. For photovoltaics applications, higher optoelectronic performance would be the much-desired enabler of a new generation of high-efficiency thin-film Si solar cells. We believe that nanostructures offer a range of opportunities for all of these application areas and that nanostructures herald a new era of silicon photonics and photovoltaics.

Silicon nanostructures for communications

Optical signals are now well established as a means for efficient data transfer from very long (Internet) to very short (rack-to-rack) distances. On-chip data processing is still being performed electronically, however, even though processor clock speeds have been limited by the interconnect problem for a number of years\(^2\). The next step-change is to introduce photonics into on-chip communications, which requires nanoscale optical sources, circuits and detectors to encode and transmit data around the chip. Silicon is poised to deliver this functionality, as silicon photonic devices are CMOS-compatible, and many highly performing devices have already been demonstrated\(^3\)-\(^12\). Photonic crystal nanostructures add unique capabilities to this toolkit, as they offer extremely tight light confinement, thus providing strongly enhanced nonlinear effects already for microwatt pump power levels\(^13\)-\(^15\), modulators with very low (femtojoule per bit level) switching energy\(^16\)-\(^18\) and the opportunity for enhancing and suppressing spontaneous emission\(^19\).

In addition to nanostructuring, many material engineering options have been explored, such as the alloying of silicon and germanium\(^19\), doping\(^20\)-\(^22\), strain and defect engineering\(^23\)-\(^25\). Arguably the most successful way to manipulate the energy structure of Si, however, is to use quantum confinement in nanostructures\(^14\). Semiconductor nanostructures — nanocrystals and nanowires — are widely investigated in view of their exciting physical properties and with an eye to possible optoelectronic, photonic and photovoltaic applications. In particular, owing to the modification of the energy structure afforded by quantization, semiconductor nanocrystals emerge as ideal candidates for photonic applications involving efficient radiative recombination. The best examples highlighting the advantages of quantization of direct-bandgap semiconductors are quantum dots\(^26\)-\(^28\), with quantization in silicon offering similar benefits, as we will explore next.

Nanocrystals and nanowires

Silicon nanocrystals have been studied intensively over the past decade\(^21\)-\(^22\). Most notably, it has been established that the excitonic emission from Si nanocrystals has two characteristic features: with decreasing crystal size, the spectrum shifts to the blue and its intensity increases. This observation indicates the quantumization-related increase of the bandgap and the enhancement of the radiative recombination rate, as momentum conservation is gradually relaxed with reducing grain size owing to the Heisenberg principle\(^29\), while the transition itself remains indirect. Further, a possible participation of oxygen and/or interface-related states has been suggested that leads to a stabilization of the photoluminescence wavelength for Si nanocrystals smaller than 3 nm in diameter\(^25\)-\(^26\). See Box 1 for a review of the fabrication methods and Box 2 for a summary of the properties of Si nanocrystals.

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The most successful methods for fabricating silicon nanocrystals are self-assembly from silicon-rich silicon oxide matrices, plasma synthesis, and colloidal chemistry. In the first case, SiO<sub>x</sub> (with x < 2) is formed by a thin-film deposition technique such as magnetron sputtering or chemical vapour deposition, or by implantation of an SiO<sub>x</sub> layer with a high dose of silicon ions. Subsequent high-temperature annealing of the substoichiometric film (typically above 800 °C) produces a phase separation between Si and SiO<sub>x</sub> with the formation of Si nanoclusters that grow by Ostwald ripening (panel a). The dimensions, crystallinity and size distribution of the nanoclusters depend on the Si excess, the temperature and the annealing time.

A variation of this method is to form a superlattice of alternating SiO<sub>x</sub> and SiO<sub>2</sub> layers. In this case, the precipitation of Si nanoclusters in the SiO<sub>x</sub> layers can be controlled to a much narrower size distribution through the thickness of the SiO<sub>x</sub> film. Plasma processing is of special interest here, as it offers the prospect of scaling up, which makes the approach particularly suitable for photovoltaic applications. Colloidal solutions of Si nanocrystals can be made from freestanding porous Si or plasma-synthesized powders, or synthesized directly using the sol–gel method or a variety of wet-chemical processes. Especially interesting properties have recently been reported for colloidal Si nanocrystal prepared by a wet-chemical oxidation–reduction method adapted from ref. 157 (panel b). This type of synthesis yields photostable and freestanding n-butyl-terminated Si nanocrystals of typically 2–3 nm in diameter. In general, one can conclude that Si nanocrystals prepared by precipitation in SiO<sub>x</sub> layers are characterized by the largest tunability range and the best stability and quantum yield of emission, whereas the colloids offer the potential up-scaling for large volumes and the advantage of low-temperature processing.

For light emission applications, Si nanocrystals can either be used directly, with the intrinsic transitions of the nanocrystals being responsible for photon generation, or indirectly, where nanocrystals enable emission from other radiant centres through energy transfer or sensitization. For the direct approach, excitonic or defect-related emission is commonly used. Excitonic emission offers the advantage of size-related wavelength tunability, but suffers from the low efficiency of phonon-assisted recombination; devices based on this emission channel remain a challenge. An additional issue is Auger de-excitation, which, however, can be mitigated by sequential electron and hole injection. Such sequential injection may be realized in a metal–oxide–semiconductor field-effect transistor (MOSFET) structure, with the Si nanocrystals being placed as a floating gate, and electrons and holes being sequentially injected by tunnelling through a thin oxide layer (Fig. 1a,b), using an a.c. voltage of typically 10 kHz (ref. 27). Indeed, luminescence is lower at lower frequency because there are only a few recombination events per unit time, but luminescence decreases again at higher frequencies because sequential injection occurs more rapidly than the radiative lifetime in silicon nanocrystals. Defect-mediated emission...
Box 2 | Properties of Si nanostructures.

Because of quantum confinement, the energy structure in a nanoconfiguration (an example for a high-resolution transmission electron microscopy image is shown in a) is influenced directly by the size of the nano-object, and accordingly can be ‘tuned’ almost at will. Additional possibilities are provided by the surface: as the surface-to-volume ratio increases with size reduction, the local arrangement of atoms located on the surface plays an increasingly important role. The combination of both effects has a profound impact on the band structure of the material and modifies both the energy and momentum dependence. Therefore, the optical bandgap and the band-to-band recombination rates can both be influenced, to the extent that an indirect-to-direct bandgap transformation can be approached. Equally, the energy bands may become discretized to such an extent that the ‘band’ concept ceases to apply and a molecular approach becomes more appropriate.

The energy structure of Si nanocrystals and nanowires has been thoroughly investigated experimentally, looking both at individual structures and at ensembles. It has also been extensively modelled and good agreement with experimental data has been obtained. Regarding the optical bandgap, tuning over a wide range of energies — from about 0.9 eV in the infrared for co-doped Si nanocrystals to above 4 eV in the ultraviolet for the smallest synthesized materials — has been demonstrated, with up to five orders of magnitude enhancement of radiative rates compared with bulk Si (see the blueshift with decreasing size in b between 700 and 1,000 nm). Surface termination and strain have been explicitly shown to produce several prominent effects. In single isolated Si nanocrystals, emission spectra show phonon replicas. In oxidized Si nanocrystals, the bandgap tunability is limited as a result of the formation of new energy levels inside the bandgap, stabilizing the photon emission energy as the nanocrystal size reduces. Finally, C-capped Si nanocrystals show an interesting radiative recombination in the nanosecond range, as opposed to typical values in the microsecond range. Silicon nanocrystals can also be doped with shallow impurities such as B or P, and in the case of co-doping, the compensated nanocrystals are preferentially formed. In such materials, emission due to donor–acceptor pair recombination is observed, also with energies below the bandgap of bulk Si (refs 163,170).

Moreover, detailed investigations have revealed other effects, such as downshift of ‘direct-bandgap’ (see the redshift with decreasing size in panel b between 400 and 600 nm) and retardation of hot-carrier relaxation rate upon size reduction, the latter arising because of a combination of the lower density of states and the so-called energy ‘recycling’ which provides hot carriers by Auger recombination of excitons localized in the same nanocrystal.

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(oxygen or carbon-related) has proved to be more successful, and devices with higher efficiencies have been reported. All of these devices are typically MOS-like structures with the oxide replaced by a nanocrystal-rich insulator (oxide or nitride). Alternatively, light-emitting devices with efficiencies of a few percent have been fabricated with nanocrystal–organic hybrids. We note, however, that so far no light-emitting devices based on Si nanocrystals have reached the market. Equally, a Si nanocrystal-based laser, despite initial successful observations of gain, has not yet been developed. One plausible yet less explored route for light emission is hot-carrier recombination, where the advantage of nanocrystals is the mitigation of phonon scattering under quantum confinement conditions. Such reduced phonon scattering slows down hot-carrier cooling, thereby enabling light emission by the phononless recombination of hot carriers, whose quantum yield increases by up to three orders of magnitude when compared with bulk Si (from 10⁻⁵ to 10⁻¹).

Although many interesting approaches for emission from direct transitions have been explored, success has been limited. The indirect approach looks more promising, especially with nanocrystals serving as sensitizers for rare-earth-doped insulating (SiOₓ) or semi-insulating (Si-rich silicon oxides or nitrides) matrices. Here, the most popular system is that of Er³⁺ ions in SiOₓ. Following the initial observation that Er³⁺ ions can be indirectly excited through photon absorption by Si nanocrystals, practical devices with efficiencies above the per cent level have now been demonstrated. Despite this encouraging performance, only a minor fraction of all Er dopants are excited, owing to the statistical distribution of Er³⁺ ions and nanocrystals, thus precluding population inversion and laser action.

A possible breakthrough to resolve this low excitation fraction could come from surface and/or strain engineering. For example, a considerable modification of the wavefunction for the low-energy electron states can be achieved by terminating colloidal nanocrystals with carbon. This termination changes the energy structure...
of the nanocrystal and hence the probability of phononless excitonic recombination. In fact, several orders of magnitude of improvement of the photoluminescence have been observed, even up to the level comparable to III–V and II–VI quantum dots46,47. The prospect for optical gain looks promising, and practical devices may be realized. The challenge here is the colloidal character of the materials, which makes electrical injection even more difficult than for Si nanocrystals embedded in SiO₂.

The electrical driving problems present in nanocrystals can be solved by using nanowires to provide the quantum confinement, although there are some technological issues that need to be addressed first. Nanowires are typically grown using the vapour–liquid–solid (VLS) mechanism40 (see Box 1), which requires high-temperature (typically >450 °C) treatments. Although this method is widely used and has led to a number of successful demonstrations, it has several drawbacks: (i) uniform doping is difficult to achieve, because the dopant needs to be included in the Si flux and is difficult to incorporate into the nanowires41,42; (ii) there is a critical size of about 10 nm below which nanowires cannot be grown, so further oxidation is required to make them thin enough for quantum confinement43; (iii) Au is incorporated within the nanowires, which introduces trap levels in the gap that enhance Shockley–Read–Hall recombination44,45. To circumvent these issues, nanowires have been fabricated either by using VLS with titanium silicide as a catalyst46 or by using electron beam lithography47,48. In both cases a subsequent oxidation step has been used to reduce the wire size. These nanowires show room-temperature luminescence compatible with quantum confinement. Metal-assisted chemical etching (MACE)59–62 (see Box 1) is a powerful alternative, in which a dense array of Si nanowires is formed by chemical etching at room temperature, allowing easy removal of the metal after nanowire formation. The size of the nanowires can be controlled by changing the metallic pattern (see Box 1). Alternatively, their size can be modulated by coupling the metal deposition with lithography or with nanosphere self-assembly. These methods allow metal-free ultrathin nanowires to be obtained, whose doping can be easily controlled by properly doping the starting silicon substrates. Indeed, nanowires as small as 5 nm in diameter have been produced that luminesce at room temperature and that exhibit the characteristic blueshift indicative of quantum confinement (see Fig. 1d,e)63–66. Nanowires are ideal for light-emitting devices, as the continuity of conduction along the wire length affords easy current flow. Indeed, electroluminescent devices62 have already been fabricated by depositing a transparent conductor (aluminium–zinc oxide, AZO) on top of the nanowires, and room-temperature performance has been demonstrated (Fig. 1f).

Light emission in silicon nanostructures was first demonstrated with porous silicon in the 1990s67. Efficient devices were fabricated through a substantial international effort, and a vast literature is available (for a review and a useful source of references on porous silicon, see for example ref. 66). The stability concerns, however, were never fully solved, and the research focus shifted towards the more stable silicon nanocrystals and nanowires. One of the challenges is the current flow within the quantum-confined structures. Although only in
Nanopatterning. The ability to control the flow of light with photonic crystals (PhCs)\(^6\) has added tremendous functionality to the silicon photonic toolkit. The full benefit of PhC light confinement is derived from three-dimensional (3D) structures, but these tend to be very difficult to make and control. Instead, researchers have made impressive progress with 2D structures that rely on total internal reflection for confinement in the third dimension\(^3\) (see Box 3). In fact, a key reason for the success of silicon nanotechnology in this field is that high-quality silicon-on-insulator (SOI) substrates are readily available and that fabrication is relatively simple and reliable; the best results are being achieved from electron-beam lithography with the resist (typically ZEP-520A) being directly used as a masking layer\(^7\). Another important feature is that some of the best results have been achieved on tools that are readily available in many laboratories; a good converted scanning electron microscope (SEM) as an electron-beam lithography tool and a basic parallel-plate reactive ion etching system may be sufficient, which is why PhC research has proliferated and many groups are engaged.

A key example for such 2D structures is the silicon line-defect PhC waveguide with engineered dispersion (see Box 3), where light can be slowed to below 1/50 of its natural speed while keeping the propagation losses low\(^8\). Application examples for such waveguides range from very compact and efficient delay lines to buffer memories and slow-light-enhanced nonlinear devices\(^2\) (Fig. 2a,b). Other examples are PhC nanocavities with ultrahigh quality factors (see Box 3) that can achieve extreme light confinement in very small spaces and provide the ultimate interaction between light and matter\(^73\)–\(^75\). For example, frequency conversion based on third-harmonic generation, which usually requires substantial pump intensity, is readily available in microscopic silicon PhC structures\(^3\) (Fig. 2c–e); effects such as optical bistability\(^4\), all-optical switching\(^2\) or four-wave-mixing\(^76\) have been demonstrated in silicon PhC nanostructures and are actively being researched.

Because the electromagnetic field intensity and the light–matter interaction in an optical cavity scale as its Q/V ratio, with Q the quality factor and V its modal volume, the quest for PhC nanocavities with a high Q/V ratio is intense. State-of-the-art silicon PhC cavities feature Q values in excess of 4 × 10\(^8\) while keeping modal volumes below (\(\lambda/\pi n\))^\(3\), where \(n\) is the effective index of the cavity mode\(^2\), and performance is increasing constantly with improvements in silicon nanofabrication. The ultimate aim of the Q/V quest is to achieve single-photon nonlinearity, and this seems to be in reach\(^8\). This means that a single photon present in the cavity may already be sufficient to realize a nonlinear response of sufficient magnitude to detune the cavity. This would allow the realization of silicon-based single-photon sources operating at room temperature through the photon-blockade effect\(^8\), thus taking silicon photonics further into quantum optics and quantum communications.

Although silicon photonics has almost reached maturity with respect to optical circuit elements, the light-source continues to challenge researchers, as already discussed above. Nanocavities may help to address this challenge, as they offer luminescence enhancement through the Purcell effect. The Purcell effect increases the radiative emission rate of an emitter interacting with an optical cavity by a factor proportional to the Q/V ratio; photonic
Planar photonic crystals are made by etching a periodic pattern (typically a triangular or square lattice of air holes) into a slab waveguide with high refractive index, such as Si or GaAs. In the case of Si, a silicon-on-insulator (SOI) planar waveguide is used as the starting material, and the patterned PhC membrane is released by removing the lower SiO₂ cladding with a HF-based wet etch (a, left panel). Typical parameters for Si PhC slabs operating at λ = 1.55 µm are a lattice constant of a = 420 nm, a slab thickness of t = 220 nm and a hole radius of r = 130 nm (ratio r/a = 0.3).

Planar photonic crystals are able to provide efficient optical confinement in all three dimensions by combining the 2D photonic bandgap confinement in the plane with total internal reflection (TIR) confinement in the vertical direction (a, right panel). In order to represent the 3D nature of the structure, the TIR confinement is superimposed on the 2D band-structure by means of the light-line: only modes whose k-vectors lie below this line are guided by TIR and can propagate without losses. All other modes are subject to radiation losses and are therefore referred to as quasi-guided modes.

A line-defect waveguide is obtained by removing a single row of holes from the lattice (b, left panel). The dispersion curve of the waveguide arises from the interplay between photonic bandgap guiding and TIR guiding in the plane (c, left panel); for the higher frequencies, the mode is TIR guided and the dispersion curve is relatively steep, whereas for lower frequencies, it is bandgap-guided and relatively flat (b, right panel). Because the group velocity is given by the slope of the dispersion curve, v₉ = dω/dk, the mode is ‘fast’ or ‘slow’ depending on the operating point. Slow-light waveguides operating close to the band-edge can attain group velocities of c/100 or lower, but propagation becomes very lossy owing to strong back-scattering, and the dispersion becomes very high. To overcome these limitations, slow-light waveguides with ‘engineered’ dispersion have been introduced that allow slow-down factors of v₉/c = 50, relatively low loss and operation bandwidths as high as 10 nm (ref. 71). High-Q PhC nanocavities confine the light further, and they can either be understood as slow-light waveguides terminated at either end, or, more fundamentally, as intentional ‘defects’ introduced into the otherwise perfect photonic lattice. In analogy with solids, such defects create allowed energy states that correspond to the resonant frequencies of the cavities. The best-known examples for such point-defect cavities include the L3 nanocavity (c, left panel), obtained by removing three holes from the triangular lattice⁸⁶, or the heterostructure nanocavity, realized by increasing the lattice constant of a W1 waveguide, thereby creating a potential well for light¹⁷²,¹⁷₄. The inventive step in both cases was the creation of a cavity mode with almost no k-vector components inside the light cone, which is achieved by a Gaussian-mode envelope. Although this insight has led to record Q-factors, now in excess of 4 × 10⁹, being achieved, there is no useful channel available to couple light from the cavity to free space (c, right panel). By superimposing a secondary lattice consisting of slightly enlarged holes (d, left panel), we have been able to engineer the far field into a near-Gaussian output beam (d, right panel) while hardly compromising the cavity Q-factor¹⁷³,¹⁷₄. Such far-field engineering has been instrumental for the successful observation of strongly enhanced linear and nonlinear light emission⁸⁸,⁹⁵,⁹₂.

Optically active defects may also be introduced directly into silicon high-Q PhC nanocavities using a simple hydrogen plasma treatment⁸⁹. The sub-bandgap luminescence from defects such as dislocation loops or hydrogen platelets is well studied¹⁷⁵,⁹⁶,⁹¹, but notoriously quenches very quickly with temperature, making light-emitting devices based on these active centres impractical. Recently, the application of the Purcell effect combined with the improved extraction efficiency from a far-field-engineered PhC nanocavity (Box 3) has proved very effective in suppressing thermal quenching up to room temperature⁸² and has led to an overall enhancement of light emission by more than four orders of magnitudes relative to the starting material, and the patterned PhC membrane is released by removing three holes from the triangular lattice⁸⁶, or the heterostructure nanocavity, realized by increasing the lattice constant of a W1 waveguide, thereby creating a potential well for light¹⁷²,¹⁷₄. The inventive step in both cases was the creation of a cavity mode with almost no k-vector components inside the light cone, which is achieved by a Gaussian-mode envelope. Although this insight has led to record Q-factors, now in excess of 4 × 10⁹, being achieved, there is no useful channel available to couple light from the cavity to free space (c, right panel). By superimposing a secondary lattice consisting of slightly enlarged holes (d, left panel), we have been able to engineer the far field into a near-Gaussian output beam (d, right panel) while hardly compromising the cavity Q-factor¹⁷³,¹⁷₄. Such far-field engineering has been instrumental for the successful observation of strongly enhanced linear and nonlinear light emission⁸⁸,⁹⁵,⁹₂.

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to bulk silicon\textsuperscript{89} (Fig. 3). Based on this surprising result, an electrically driven nano-light-emitting-device source was also realized\textsuperscript{86}. The device operates in a continuous-wave manner at room temperature and exhibits a narrow linewidth in the technologically important wavelength window at 1,300–1,600 nm. It is small and features low power consumption. Although it shows the highest power spectral density ever reported for a silicon light-emitting device (800 μW nm\textsuperscript{−1} cm\textsuperscript{−2}), it does not yet produce sufficient power output; otherwise, it would combine all of the desired characteristics of an integrated light source, especially given that CMOS-compatible detector technologies are also available in this wavelength range\textsuperscript{93, 94}. Nevertheless, the ability to improve the light emission properties so greatly with photonic crystal nanocavities is a very encouraging step towards the realization of all-silicon-based light sources.

Overall, a wide range of silicon-based nano-emitters have now been demonstrated, some of which show very respectable efficiency, reaching up to about 10% (refs 31, 66). Even though this is impressive for an indirect-bandgap semiconductor, the brightness of such emitters is typically low and the wavelength of emission tends to be in the visible or the very near infrared (λ < 1.1 μm), where they have to compete against organic light emitters and highly efficient GaAs sources. We believe that a promising regime is the wavelength range 1.3–1.6 μm, where silicon emitters complement the extensive silicon photonics toolkit\textsuperscript{84,85,89,92} and, combined with suitable detectors\textsuperscript{93, 94}, offer the complete chain from emitter to signal-processing circuitry to detector. Furthermore, cavity-enhancement of emission is available\textsuperscript{84,85,89,92}, which can enhance efficiencies by two to three orders of magnitude\textsuperscript{92, 95}. Emitters demonstrated in this regime include those based on defects, dislocations and strain\textsuperscript{16, 17, 86–91} or erbium doping\textsuperscript{86–88}, some of which have shown surprisingly high brightness\textsuperscript{89} yet still suffer from low efficiency. The combination of nanowires and photonic crystal cavities seems particularly promising in this respect. The challenge is now to develop these concepts further as a combination of material and photonic nanostructure design in order to reach performance that can compete with integrated hybrid devices based on III–V semiconductors on silicon. Reaching such performance will signify a true breakthrough and herald the beginning of an all-silicon photonic technology.

**Silicon nanostructures for photovoltaics**

One of the greatest challenges facing mankind is the provision of clean energy to fuel our economies; solar cells will make an...
important contribution to this challenge as part of the renewable energy mix. Of the many possible materials proposed and demonstrated for making photovoltaic solar cells, silicon is the only one that combines suitable optoelectronic properties with Earth-abundance and technological availability. Currently the highest demonstrated photovoltaic conversion efficiency of a Si solar cell is near 25%, which has been realized in a single junction configuration19. This is very close to the Shockley–Queisser limit of about 30% (ref. 97), and therefore only limited further progress can be expected. At the same time, Si tandems that make use of crystalline, micro/poly crystalline and amorphous forms of Si have not been able to surpass this efficiency. Consequently, the value of 25% represents the general present-day record efficiency for Si-based photovoltaics. Water-based ‘bulk’ silicon cells currently dominate the market, yet only thin-film cells will be cost-effective in the long run, as they do not require much active material and can be produced cheaply using flow-through processes on metre-sized substrates. The main trade-off of thin-film versus bulk solar cells is their reduced absorption, which introduces the need for light-trapping schemes that increase the effective absorption length of the thin-film material. Nanopatterning, quantum confinement and surface-induced effects in Si nanostructures offer interesting features that could be used to boost the efficiency of photovoltaic energy conversion and to overcome some of the restraints that lead to the Shockley–Queisser limit20. Specific ‘photovoltaic opportunities’ follow from (i) the possibility of bandgap engineering, through nanocrystals and nanowires, to modify absorption and extraction, and (ii) the possibility of new light-trapping schemes through nanopatterning.

Nanocrystals and nanowires. Silicon nanocrystals present several properties of importance for photovoltaics: (i) the possibility of tuning the bandgap and the recombination rate through quantum confinement and dedicated surface termination; (ii) the reduction of the density of states and discretization of energy levels that affect hot-carrier cooling processes; and (iii) the enhancement of the Coulomb interaction between carriers enclosed in small volumes, promoting collective effects such as multiple carrier generation (MEG)21,22 and ‘Auger recycling’23. But these advantageous properties do not arise without a price: the potential barrier that aids quantum confinement also impedes carrier extraction to the outside. In particular, this problem is notorious in all concepts of (the third-generation) solar cells based on nanocrystals. For the most readily available and most investigated system of Si nanocrystals in the solid matrix of SiO2, the relevant potential barrier for free electrons is around 3 eV. Therefore, extraction of photogenerated carriers has to invoke tunnelling and percolation between closely spaced nanocrystals (forming ‘quantum solids’) which is not efficient. Several different approaches are under investigation, such as the fabrication of Si nanocrystal/organic hybrid solar cells24. Nanocrystals can be produced by plasma processing with the advantage of a scalable mass production for photovoltaic devices25–29. Demonstrated power conversion efficiencies are limited to a few per cent30,31, because of the low carrier mobility, although progress can be expected. Indeed, the formation of defect/impurity-related minibands linking individual nanocrystals32,33, or dispersions in several conducting media (macroporous TiO2 polymers), is also under investigation. It seems that the ultimate solution would be a highly conductive medium with only a minimal conduction-band offset; some investigations suggest that a potential barrier as small as 0.1 eV would be sufficient to preserve advantages of quantum confinement while minimizing extraction loss. Nevertheless, the efficient extraction of free carriers from a confined environment remains a challenge.

An interesting solution to this problem may again be offered by Si nanowires. In analogy with the light-emission discussion, quantum confinement takes place in two dimensions, whereas carriers can be extracted along the third. Silicon nanowire solar cells have already been fabricated both on a single wire34,35 and on nanowire arrays36. Two main schemes are used37,38: axial junctions39,40, in which the p–i–n diode is fabricated along the length of the nanowire by varying the doping density during growth; and radial junctions41,42, in which the diode is fabricated coaxially by a core–shell method. The advantages of using silicon nanowires for solar cells are manifold. First of all, nanowire arrays are extremely strong absorbers43,44, as the light remains trapped inside the nanowire forest by multiple scattering events. Second, radial junctions have the advantage of a very short electrical path-length for carrier extraction, which would suggest the potential for significant performance improvements. In fact, efficiency depends on a compromise between the extracted current (increasing with decreasing nanowire radius) and open-circuit voltage (decreasing with increasing junction area, and hence with decreasing nanowire radius). Optimal radial junctions have a radius similar to the minority-carrier diffusion length to allow full collection without decreasing the voltage too much. A challenge is then to achieve the required high doping density needed to avoid depletion with decreasing nanowire size. In principle, quantum confinement could also be used to build cells in which the nanowires form the top part of a cell, which is transparent to less energetic photons that are absorbed at the bottom.

Both VLS growth and the MACE method have been used successfully to obtain nanowire solar cells45,46,47. In a nanowire solar cell the nanowire ‘carpet’ can be conformally covered by a transparent electrode such as AZO embedded within a conductive polymer or alternatively infiltrated by a liquid electrode. The resulting solar cells have all the advantages of a highly absorbing material with a radial, low-path, carrier extraction. One might expect that the better performance is obtained by maximizing carrier extraction and hence carrier lifetime, which is, indeed, achieved by minimizing trap centres. This is in principle easier with the MACE method, as trap generation is at room temperature and the detrimental effect of metal diffusion does not occur. In fact solar cells with efficiencies over 10% have already been claimed48, with further progress being expected.

Silicon nanostructures not only allow us to make traditional ‘photon-in/electron-out’ photovoltaic devices; they can also form the basis of an autonomous device — a ‘solar shaper’. Such a photon-in/photon-out scheme does not involve carrier extraction, but it would be used to extract energy from the parts of the solar spectrum that are otherwise not efficiently converted. It therefore rectifies the fundamental reason for the limited efficiency of photovoltaic conversion: the mismatch between the broadband character of solar radiation and the narrow window of optimal performance of a semiconductor photodiode. A solar ‘shaper’ could form an add-on that supplements the traditional cell and converts the incoming broadband spectrum into a new spectrum that is narrower and better optimized for absorption by a single-junction solar cell. This would require the ‘cutting’ of high-energy ultraviolet photons into multiple lower-energy quanta that can be converted more efficiently, as well as the ‘pasting’ together of low-energy photons in the near infrared that are otherwise not converted at all. Silicon nanocrystals offer interesting possibilities that could be used for both processes.

For photon cutting, the MEG process mentioned previously could be used (Fig. 4a). In this process, a highly energetic hot carrier relaxes by generating additional electron–hole pairs. MEG is usually seen as a direct analogue of impact excitation in bulk materials, whose efficiency in nanocrystals is enhanced by a high density of carriers in a strongly confined environment. The effect was first reported in nanocrystals of direct-bandgap materials49 and later also in (colloidal) Si (ref. 118). Dedicated investigations confirmed that the efficiency of this process in nanocrystals is considerably enhanced when compared with bulk materials of the same band-gap50,51. Applied to photovoltaics, MEG would create more than
one electron–hole pair per single absorbed high-energy photon, thereby creating additional photocurrent from the green and blue part of the solar spectrum. Indeed, theoretical evaluations indicate that total conversion efficiencies of up to ~50% are feasible — that is, efficiencies well above the Shockley–Queisser limit. The lifetime of the multiple carriers generated in this process is limited by their Auger interaction and depends on the nanocrystal size and carrier multiplicity, but generally remains in the subnanosecond range, which is too short. For dense solid-state dispersions of Si nanocrystals in SiO₂ (ref. 123), however, multiple excitons that are generated on absorption of a single high-energy photon can appear not in the same but in neighbouring (coupled) nanocrystal. The separated excitons are now both able to recombine radiatively. Photon pasting. The most important properties in this respect are (i) the identification of phononless recombination, (ii) a significant reduction of the cooling rate for hot carriers, (iii) a large cross-section of free carriers for the absorption of infrared photons, and (iv) defect-related hot-carrier photoluminescence. These properties, especially in combination, open perspectives for photovoltaic conversion of infrared photons that are otherwise lost. Two specific approaches that make use of such combined effects are currently under investigation (see Fig. 4). The first is the absorption of low-energy photons by free carriers for the generation of hot excitons, followed by carrier multiplication, shown in Fig. 4c, or trapping at the Si–O related defect and subsequent ‘blue’ emission at ~420 nm (refs 126,127). We point out that because the 420-nm wavelength of the hot defect-related emission is fixed, the absorption of the infrared photons can be tailored by changing the nanocrystal size, as highlighted in Fig. 4d. A second approach makes use of the non-linear properties of Si nanocrystals, more specifically the combined...
Figure 5 | Supercell binary grating for light trapping. The supercell geometry provides all of the necessary degrees of freedom to maximize light trapping, while being easy to fabricate. The figure highlights the structure’s ability to excite the quasi-guided modes of the thin film while diverting the diffracted energy away from the orders that transmit in a single pass.

absorption of two (or more) low-energy photons for the generation of a single low-energy electron–hole pair.\(^1\)

In general, in addition to these opportunities and unique properties, Si nanostructures offer one key advantage over other approaches for next-generation photovoltaics, namely the use of Si itself. Silicon nanostructures add the important degrees of freedom of bandstructure engineering and surface modification to the abundance, minimal environmental footprint and technological maturity of the Si material.

**Light trapping.** The main trade-off of thin-film versus bulk solar cells is their reduced absorption, which introduces the need for light-trapping schemes that increase the effective absorption length of the thin-film material. Nanophotonic techniques are particularly promising for the purpose of light trapping, as they allow us to control the flow of light on the length scale of several 100 nm to a few micrometres that is required for thin-film solar cells. Researchers are pursuing two different paradigms, plasmonic and diffractive light trapping; here, we focus on diffractive effects, as we believe that the inevitable absorption incurred by plasmonic nanostructures makes it even more challenging to achieve the desired high efficiencies, and to convert every incoming photon into an electron–hole pair (for a recent review on plasmonics for photovoltaic devices see ref. 129).

The key figure of merit for any light-trapping scheme is the Lambertian limit, which has a maximum value of \(4\pi^2\) and is a measure for the achievable pathlength compared with a single pass through the material; a photon may travel up to \(4\pi^2\) times further than without light trapping, and hence increase its chances of being absorbed. The \(4\pi^2\) limit assumes very weak absorption, and only applies if the path-length is much smaller than the absorption length; for thicker or more strongly absorbing materials, it is correspondingly smaller. For example, for a 100-nm-thick crystalline silicon film, light trapping close to the Lambertian limit may be achieved, whereas a factor of 2 is the most that can be expected for an amorphous Si (a-Si) film of the same thickness. An additional effect of nanostructures is their ability to completely suppress back-reflections, which has led to the term ‘black silicon’ being used to describe this property.

What type of structure to use in order to achieve light trapping in a thin-film solar cell is a question that is actively being researched, with the options ranging from random surface roughness, which excites many diffraction orders, to ordered gratings that only excite a few. Recent trends indicate that the optimum light-trapping structure lies somewhere in-between; the diffraction orders generated by random scattering are too weak, but there are not enough of them created by regular ordered gratings. Furthermore, neither extreme provides sufficient degrees of freedom to account for the wavelength-dependent absorption of the active layer. Accordingly, a number of structures that have been developed using numerical optimization techniques appear quasi-random or periodic with a more complex unit cell. Similarly, structures making use of multiple light scattering and wave interference in two-dimensional random media have shown increased light-trapping properties, as have periodic structures that were partially randomized and randomly rough structures with Gaussian disorder. Structures with more complex three-dimensional unit cells are also being investigated and have shown light-trapping performance close to the Lambertian limit, but they are more challenging to fabricate, especially on the large scales required for cost-effective mass-production. The consideration of mass-manufacturability adds an important boundary condition, namely that of simplicity, which drives the search for structures such as binary gratings that are intrinsically easy to make yet still high-performing (see Fig. 5).

Ultimately, researchers aim to surpass the Lambertian limit, especially as this limit was derived for thick-film cells and relies on geometric optics, whereas for thin-film cells, wave optics rules. Proposals for new structures that may surpass this limit in the wave-optics regime and for a limited wavelength range have already been made, but an experimental structure that surpasses the Lambertian limit for all angles and in the full wavelength region of interest remains elusive and poses an exciting research challenge for the future.

A further challenge is to use light-trapping techniques without compromising the electro-optic properties of the material. For example, etching a nanostructure into silicon greatly increases the surface recombination velocity, with values up to \(10^5\) cm s\(^{-1}\) having been reported, which severely degrades the photovoltaic efficiency. A possible solution to this issue may be a thin film deposited by atomic layer deposition, which has shown promising improvements, or the careful control of the surface doping profile, which can be used to limit both surface and Auger recombination. Alternatively, the active silicon film may be deposited onto a pre-patterned substrate, but then the material properties of the film may also be compromised.

To summarize, silicon, owing to its Earth-abundance and near-optimum electronic bandgap, is the prime candidate for realizing large-scale photovoltaic systems. Reducing the amount of material while maintaining high efficiencies is the key research goal in order to drive cost reduction. A number of silicon nanostructures have now been demonstrated for enhancing performance, for example by multiplying carriers through ‘photon cutting’ (MEG) by reducing reflections (black silicon) or by maximizing absorption through careful bandgap engineering (quantum dots and nanowires) or through light trapping in thin films.

Designs based on random, amorphous and periodic (including ‘quasi-random’ periodic) nanostructures have been proposed, with very promising performance being predicted. The figure of merit that is emerging to describe such light-trapping nanostructures is how close the performance of the nanostructure comes to the ideal scattering (Lambertian) limit. Using advanced designs, the performance may even be extended beyond that of a Lambertian scatterer by taking wave-optics effects into account. Objective comparisons of the different types of structure discussed in the literature are difficult, however, as the maximum enhancement achievable with a given nanostructure depends on the nature of the material.
(for example, a-Si versus c-Si or III–V) and its thickness; how the nanostructure affects the electro-optic performance of the solar cell, for example through parasitic absorption in the contacts, or through surface and Auger recombination, is another important issue, as well as the question of whether the overall performance of a solar cell can be enhanced using ‘solar shapers’ that convert the spectrum in order to optimize electron–hole pair generation. Given the intense pressure on the cost-effectiveness of solar cells, the key challenge is to design nanostructures that enhance the electro-optic performance of the cell while being manufacturable at large scale and at sufficiently low cost.

Challenges and perspectives
Silicon, as a monatomic crystal, offers only very limited degrees of freedom for manipulating its optoelectronic properties. It is therefore impressive how many methods, mainly based on nanoscale engineering, have been developed to extend its capabilities. These methods either manipulate silicon’s intrinsic electronic properties using quantum size and surface effects or they add photonic functionality through wavelength-scale nanostructures such as photonic crystals. We have provided an overview of the most promising of these methods and have outlined the outstanding challenges.

Silicon nanocrystals, without doubt, have been one of the most important developments in the field, as they offer strong carrier confinement and modification of the energy levels through quantization, as well as the ability to use their surface as a further design parameter. This has now led to the truly remarkable observation of photoluminescence levels from these nanocrystals that are comparable to those of direct-bandgap quantum dots. Electroluminescence remains a challenge, however, because the dielectric matrix (typically SiO₂) makes it difficult to inject and extract carriers. Silicon nanowires offer an interesting alternative, as they combine strong confinement with a readily available conduction path. Such nanowires are still in their early stages of development, however, with the main challenge being the development of a reliable and impurity-free growth method. Once this has been achieved, we can look forward to silicon nanostructures combining quantum-dot-like optical properties and with electrical conduction that may ultimately rival III–V materials.

An alternative to the bottom-up creation of nanocrystals and wires is the top-down incorporation of photoactive defects into the silicon matrix. Many studies on such defects have been performed, but surprisingly little is known about their light-emission properties. Recent studies linking these defects to strong luminescence have revitalized the interest, especially following the remarkable demonstration of light emission of similar strength to that from comparable III–V photonic crystal cavities. If one could better control the nature of the photoactive defects and increase their density, thereby increasing the spectral density of emission, a true all-silicon laser might well be in reach.

Regarding wavelength-scale photonic nanostructures, photonic crystals have clearly proved their value as part of the silicon photonics toolkit; in addition to enabling some of the smallest and lowest-power modulators for communications applications, they offer the highest Purcell enhancement of any known resonant system and are therefore essential for any application involving radiative transitions. The main issue is that the surface damage incurred during their fabrication leads to high surface recombination velocities, which is detrimental to both light emitters and solar cells. Recent demonstrations involving atomic layer deposition have shown, however, that the surface damage can be mitigated to a considerable extent.

Silicon nanostructures have mainly been developed with light emission and propagation in mind, but many concepts can readily be applied to the complementary problem of light absorption in solar cells. Arguably, silicon is the only viable material for the large-scale production of solar cells, owing to its abundance and technological maturity, so improving its light-trapping properties is a worthwhile pursuit. Correspondingly, a number of authors have now proposed solutions that can reach the Lambertian limit of maximum absorption enhancement in thin-film solar cells. The main challenge is to implement light-trapping designs in electrically viable material and to ensure that the designs can be realized on the required large areas (‘nanostructures on square metres’) in a cost-effective manner. From the design perspective, an exciting question is whether the Lambertian limit can be beaten across the relevant solar spectrum, which would provide a further boost to solar-cell efficiency.

Given the large market pull for photonic technologies and the many innovative solutions provided by industrial and academic research groups, there is no doubt that Si photonics will mature further and will evolve to become the dominant technology also in photonics. We hope that our Review will contribute to this development and that it will provide inspiration for even better solutions.

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NATURE NANOTECHNOLOGY

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Competing financial interests

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